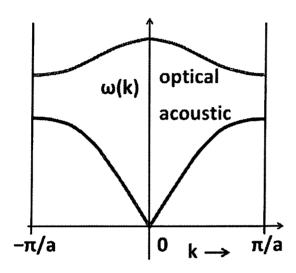
a)

Goldstone theorem states that a broken continuous symmetry in presence of short range interactions results in collective mode of excitations that has no gap, which means the energy dispersion curve remains continuous even at 0 energy.

A typical classical example would be acoustic phonon because continuous rotational symmetry is broken during the formation of crystal.



Solutions to Assignment #4:

Three independent sets of solutions by:

- 1) Kevin Lee
- 2) Zach Zeigler
- 3) Sanjeev Kolli

b) 
$$S(\vec{q}) = \frac{1}{N} \left| \sum_{i} e^{i\vec{q} \cdot \vec{R}_{i}} \right|^{2}$$
where  $\vec{q} = \vec{k}_{out} - \vec{k}_{in}$ 

Let's assume the lattice vector is a

$$S(\frac{7}{7}) = \frac{1}{N} | \sum_{n=1}^{N} e^{i\frac{\pi}{7}na} |^{2}$$

$$= \frac{1}{N} \left| \frac{\left(1 - e^{Niqa}\right)}{\left(1 - e^{Niqa}\right)} \right|^2$$

$$= \frac{1}{N} \left( \frac{1 - e^{Niqa}}{1 - e^{Niqa}} \right)^{2}$$

$$= \frac{1}{N} \left( \frac{1 - e^{Niqa}}{1 - e^{-iqa}} \right) \left( \frac{1 - e^{-iqa}}{1 - e^{-iqa}} \right)$$

$$= \left(\frac{1}{N}\right) \left(\frac{1 - e^{i\varphi a}}{1 - e^{i\varphi a}} - \frac{e^{Ni\varphi a}}{1 - e^{i\varphi a}}\right) = \left(\frac{1}{N}\right) \left(\frac{2 - 2\cos(N\varphi a)}{2 - 2\cos(\varphi a)}\right)$$

$$= \left(\frac{1}{N}\right) \frac{2 - 2\cos(\varphi a)}{1 - e^{i\varphi a}}$$

$$= \left(\frac{1}{N}\right) \frac{\sin^2\left(\frac{N\varphi a}{2}\right)}{\sin^2\left(\frac{\varphi a}{2}\right)}$$

$$= \sin^2\left(\frac{\varphi a}{2}\right)$$

Note: 
$$2 \sin^2 \alpha = 1 - \cos 2\alpha$$

$$= \left(\frac{1}{N}\right) \frac{\sin^2\left(\frac{N\varphi a}{2}\right)}{\sin^2\left(\frac{\varphi a}{2}\right)}$$

## Problem 4.1)

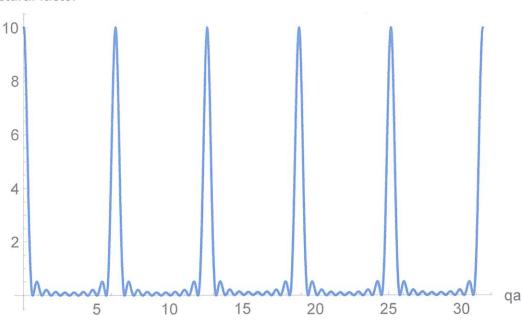
c) According to the structure factor equation for 1D perfect lattice.

$$S(q) = \frac{1}{N} \frac{sin^2(\frac{Naq}{2})}{sin^2(\frac{aq}{2})}$$

We can plot the structure factor by Mathematica.

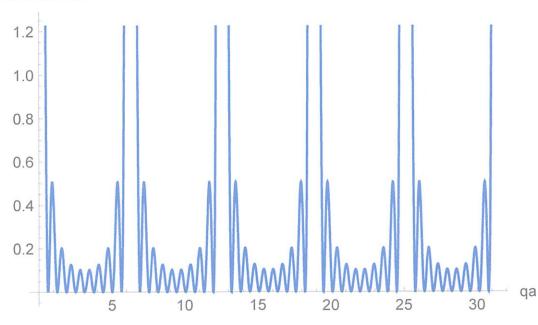
This is the plot of N=10 atoms.

Structural factor



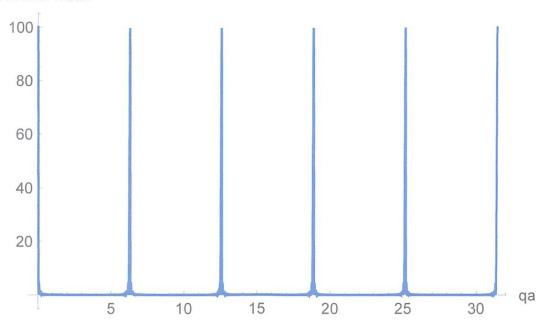
If we zoom in, the following figure, we can see there are 10 peaks in between maximum peaks. And the maximum peak value is 10.

Structural factor



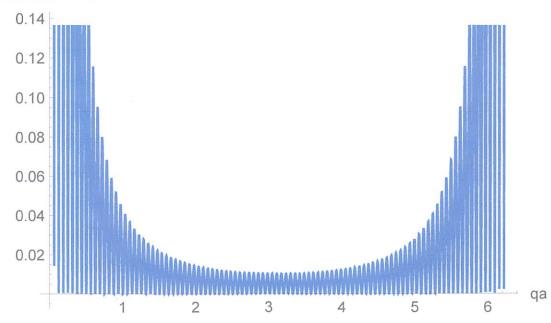
### Then I made the plot of N=100.

Structural factor



If we zoon in for  $0 < qa < 2\pi$ , we can see the small satellite peaks in between.

Structural factor



To prove the structure factor's maximum value, we need to observe the behavior of the sine function.

First, when  $\frac{qa}{2}=n\pi$ , "n" is an integer, the function  $sin(\frac{aq}{2})$  goes to zero. But the structure is not divergent since  $sin(\frac{Naq}{2})$  also has zero value.

To get the value of  $\frac{sin(\frac{Naq}{2})}{sin(\frac{aq}{2})}$ , we need L' Hospital's rule.

L' Hospital's Rule

Suppose f(c) = g(c) = 0, and  $g'(x) \neq 0$ .

$$\lim_{x \to c} \frac{f(x)}{g(x)} = \lim_{x \to c} \frac{f'(x)}{g'(x)}$$

Therefore, we have

$$\lim_{\substack{\underline{dq} \\ \frac{q}{2} \to 0}} \frac{\sin(\frac{Naq}{2})}{\sin(\frac{aq}{2})} = \lim_{\substack{\underline{dq} \\ \frac{q}{2} \to 0}} \frac{N\cos(\frac{Naq}{2})}{\cos(\frac{aq}{2})} = N$$

$$S(q=0) = \frac{1}{N} \times N^2 = N$$

Hence, we proved that the maximum value is "N" for structure factor.

Now we prove that there are N peaks in between two maximum peaks.
 Effectively, each peak lies in between two consecutive minimum.
 Therefore, we can calculate peak number based on the number of minimum points in between 0 and 2π.

When the function has zero values, it means  $sin^2\left(\frac{Nqa}{2}\right)=0$ .

$$\frac{N}{2} \times qa = n\pi$$
, where  $n = integers$ 

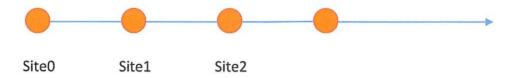
$$qa = \frac{2\pi n}{N}$$

It is obvious that n=0,1,2,3,...,N, then  $qa=0\to 2\pi$ . So the total satellite peaks including the two maximum peaks is exactly "N".

Or we can argue this problem in another way, looking how many maximum values for ga in between 0 and  $2\pi$ . Basically, it's the same problem.

#### Problem 4.1)

d) Now we need to remove three atoms randomly in the 1D lattice. The 1D lattice can be viewed as following.



I chose to remove the site 2,5 and 8 atoms. If we look at the original structure factor equation instead of the calculated form in problem 4.1c. The form is easier to understand. This is the original structure factor without vacancies.

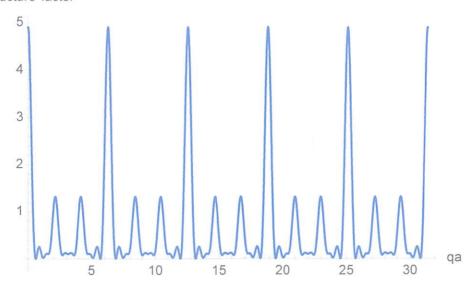
$$S(q) = \frac{1}{N} \left| \sum_{n=0}^{N-1} e^{iqna} \right|^2$$

If we want to add vacancies, we can just plug in the minus lattice site term in the above expression.

$$S(q) = \frac{1}{N} \left| -e^{2iqa} - e^{5iqa} - e^{8iqna} + \sum_{n=0}^{N-1} e^{iqna} \right|^2$$

So we can make the plot for N=10.

Structure factor

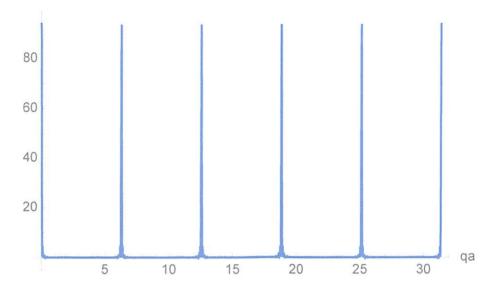


This maximum peaks' intensities are decreased. If we calculated the peaks in between the two maximum peaks, there are still 10 peaks.

For N=100, I chose site 2, 50, 77 to be vacancies.

$$S(q) = \frac{1}{N} \left| -e^{2iqa} - e^{50iqa} - e^{77iqna} + \sum_{n=0}^{N-1} e^{iqna} \right|^2$$

Structure factor



I would say that diffraction experiment is a good tool to determine the crystal quality of a semiconductor. From these calculations, we can see that as long as there are vacancies in the crystal, the diffraction peaks' intensity decreased. But I wouldn't say it's good for determining exact number of vacancies in the crystal. It is only suitable to compare two identical crystals' quality. The one with higher diffraction peaks has better crystal quality, which means less vacancies here.

Problem 4.2)

Toblem Tidy

$$\begin{array}{lll}
\widehat{R}_{j} \rightarrow \widehat{R}_{j} + \widehat{u}_{j}(t) & \widehat{R}_{k} \rightarrow \widehat{R}_{k} + \widehat{u}_{k}(t) \\
\widehat{S}(\overline{g},T) &= \frac{1}{N} \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}_{j} + \overline{u}_{j}^{*}(t)) \right]^{\frac{1}{N}} \\
&= \frac{1}{N} \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \right] \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \right] \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \right] \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \right] \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \right] \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \right] \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \right] \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \right] \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \right] \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \cdot e^{i \overline{g}_{j}} \cdot (\overline{g}_{j}^{*} - \overline{u}_{k}^{*}) \right] \\
&= \left( \frac{1}{N} \right) \left[ \sum_{j=k}^{N} e^{i \overline{g}_{j}} \cdot (\overline{g}$$

Problem 4.d)

b) From a), we have 
$$\vec{S}(\vec{g},T) = \vec{S}(\vec{g},T=0) e^{i\vec{g}\cdot\vec{\Sigma}_{i}}(\vec{u}_{j}(t)-\vec{u}_{k}(t))$$

$$(*) e^{i\vec{q}\cdot\Sigma(\vec{u}_j-\vec{u}_k)} = 1+i\vec{q}\cdot\Sigma(\vec{u}_j-\vec{u}_k) - \frac{1}{2}(\vec{z}\cdot\Sigma(\vec{u}_j-\vec{u}_k))^2 + \cdots$$

Assume each lattice point oscillate independently.

$$\Rightarrow \quad \vec{g} \cdot \Sigma \left( \vec{u}_j - \vec{u}_k \right) = 0$$

Assume the angle between \( \frac{1}{2} \) and \( \vec{u}\_{j} - \vec{u}\_{k} \) is "O."

$$\frac{1}{2} \left( \vec{g} \cdot \vec{\Sigma} (\vec{u}_j - \vec{u}_k) \right)^2 = \frac{1}{2} \left( \cos^2 \theta \right) \vec{g}^2 \vec{\Sigma} |\vec{u}_j - \vec{u}_k|^2$$

$$= \frac{1}{2} < \cos^2 \theta > g^2 \sum (|\vec{u}_j|^2 + |\vec{u}_k|^2 - 2\vec{u}_j \cdot \vec{u}_k)$$

 $= \frac{1}{2} \langle \cos^2 \theta \rangle q^2 \sum_{k=1}^{\infty} ||\vec{u}_k||^2 + ||\vec{u}_k||^2 - ||\vec{u}_k||^2 + ||\vec{u}_k||^2 - ||\vec{u}_k||^2 + ||\vec{u}_k||^2 - ||\vec{u}_k||^2 + ||\vec{u}_k||^2$ 

$$= \frac{1}{2} < \cos^2 o > q^2 \sum_{i} 2|\vec{u}_{i}|^2$$

1 geometrical average over a sphere.

$$= \frac{1}{2} \cdot \frac{1}{3} \cdot 2 \sum_{j} |\vec{a_{j}}|^{2} q^{2} = \frac{1}{3} \sum_{j} |\vec{a_{j}}|^{2} q^{2}$$

$$(*) \sim 1 - \frac{1}{3} q^{2} \sum_{j} |\vec{n}_{j}|^{2} + \cdots$$

$$\approx e^{-\frac{1}{3}i} \sum_{j=1}^{3} |\vec{u}_{j}|^{2}$$

Problem 4.d)

b) Now we need to solve  $\sum |\vec{u}_j|^2$ .

For a simple harmonic oscillator, energy is the following.

$$\frac{1}{2} M \omega_0^2 \sum_j |\vec{u}_j|^2 = \frac{3}{2} k_B T$$

3D thermal average energy

$$\sum |\vec{u_j}|^2 = \frac{3k_BT}{M\omega_0^2}$$

$$(X) = e^{-\frac{1}{2}g^2} \cdot \frac{8kBT}{Mw_0^2} = e^{-\frac{g^2kBT}{Mw_0^2}}$$

- $S(\overline{q},T) \approx S(\overline{q},T=0) e^{-\frac{q^2k_8T}{M\omega_s^2}}$
- C) For 1D case, we need to modify two things in the previous derivation.
  - 1. Thermal average energy = \frac{1}{2} k\_8T
  - 2. Geometrical overage (Cseto) = 1

$$\int \sum_{i} |u_{ij}|^{2} = \frac{k_{B}T}{M\omega_{o}^{2}}$$

$$\approx e^{-\frac{7 + 61}{M w_{*}^{2}}} \Rightarrow$$

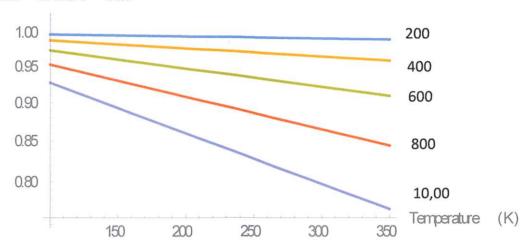
$$S(\vec{q},T) = S(\vec{q},T=0) e^{-\frac{\vec{q} \cdot \vec{k} \cdot \vec{l}}{M \omega_s^2}}$$

#### Problem 4.2)

d)

First, we can plot the similar figure with the 1D lattice structure.

Normalized Structure factor



Although the 1D lattice model is not correct for Al, we can capture the main characteristics of the measurement data.

The  $\,\mathbf{q}\,$  vector is the reciprocal lattice vector. In 3D system, it can be written as following form.

$$\mathbf{q} = \mathbf{h}\mathbf{b}_1 + \mathbf{k}\mathbf{b}_2 + \mathbf{l}\mathbf{b}_3$$

h,k,l are the Miller index.  $b_1$ ,  $b_2$  and  $b_3$  are the reciprocal lattice vectors.

$$b_1 = \frac{2\pi}{a}$$

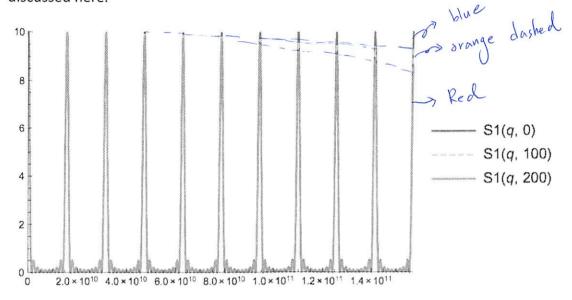
When we change the injection angle of X-Ray, we are observing different planes of the crystal. When the crystal plane's Miller index is larger, the Debye Waller factor will decrease.

$$S(\mathbf{q}, T) = S(\mathbf{q}, T = 0)e^{\frac{-k_B T q^2}{M\omega_0^2}}$$

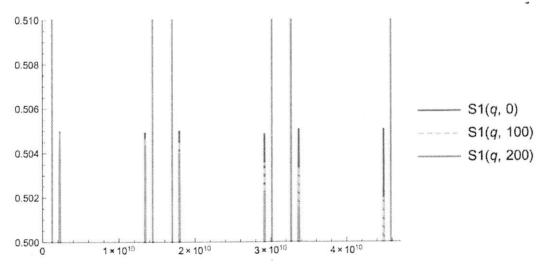
h î, q î, 
$$e^{\frac{-k_BTq^2}{M\omega_0^2}}$$
 ↓,  $S(\mathbf{q}, T)$  ↓

This characteristic is shown in the figure. (10, 0, 0) has the smallest value. As the temperature increases, the exponential factor will decrease further, too. The structure factor will decrease accordingly.

The figure above is calculated by the first maximum peak's intensity. If we make plots of structure factor for different temperature, we can see the peak intensity decreasing as q value increases, which is the same thing for increasing Miller index discussed here.



The blue line is structure factor for zero K. Orange dashed line is structure factor for 100K. Red line is structure factor for 200K. The horizontal axis is the q vector. As we increase Miller index, q vector value increases, which means moving along positive x direction in the plot. We can there is a drop in the peak intensity as q increasing. In addition, the peak intensity decreases as the temperature rises. Both observations are consistent with the provided plot in the problem.



This is a zoom in image of the above diagram. The satellite peaks are also decreasing.

Problem 4.2)

e)

If we want to utilize the temperature dependence of structure factor, the best scenario is that the intensity variation is large when temperature changes.

From Debye Waller factor, we can analyze the problem.

$$S(\mathbf{q},T) \propto e^{\frac{-k_B T q^2}{M\omega_0^2}}$$

In order to have large variations, we can choose materials with smaller mass or smaller resonant frequency.

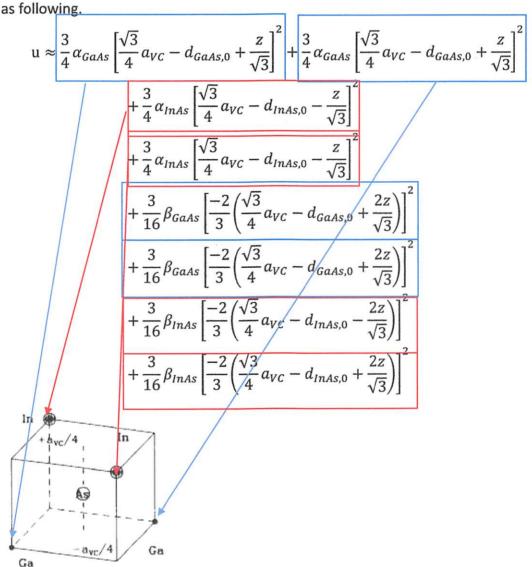
The other strategy would be using large Miller's index peaks as reference. This is similar to our argument in the previous problem. Large Miller's index corresponds to larger q value, and this makes exponential term more sensitive to temperature.

#### Problem 4.3)

a)

If we want to generate the fig. 3, we need to first determine the strain energy dependence on the composition as the fig 2.

To generate this plot, we need to consider the microscopic strain and bending energies of different configuration. The total microscopic energy can be written according to Chapter 4 of Taso's book. For Type 2 configuration, we can write down



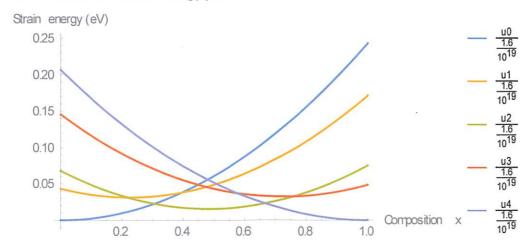
If we want to calculate different configuration, we just change the alpha, beta constants, and the equilibrium bond length. Red box terms correspond "In" atom position. Blue box terms correspond to "Ga" atom position.

To find each configuration's equilibrium energies, we can take derivative of z to the strain energy.

$$\frac{\partial u}{\partial z} = 0$$

We will find an equilibrium value of z, then substitute this value into total strain energy equation. We have the strain energy of each configuration.

Note that  $a_{VC} = (1-x)a_{InAs} + xa_{GaAs}$ , which is the virtual crystal approximation. Now we can make strain energy plot.



"ui" is the total strain energy of configuration "i". From this diagram, we can see that the strain energy is composition dependent.

For completely random atom distribution, the plot is very easy.

$$\alpha_i x^{4-i} (1-x)^i$$

This is the proportion of "i" configuration.

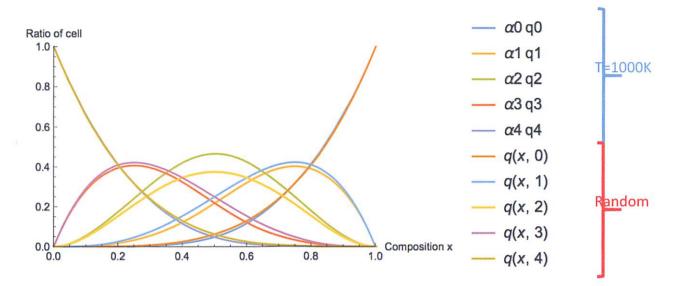
To get the Fig 3. in the paper, we need to consider the strain energy into free energy and use Lagrange multiplier to get the equilibrium distribution of each configuration. Basically, we have to solve Eq. 12 in the paper.

$$(1-x)\eta_0 t^4 + (3-4x)\eta_1 t^3 + (3-6x)\eta_2 t^2 + (1-4x)\eta_3 t^1 - x\eta_4 = 0$$

where  $\eta_i=e^{\frac{-\epsilon_i}{k_BT}}$  and  $t=e^{\frac{-b}{4k_BT}}$ . " $\epsilon_i$ " is the strain energy of ith configuration. "b" is a constant to be solved in the equation. For simplicity, I solved "t" in the equation instead of "b" since it's too complicated to solve "b" directly. Since it is a forth order equation, there will be four solutions. But there is only one solution can give us the final result. After solving "t", we can get the ratio of each configurations as following.

$$\alpha_i q_i = \alpha_i c \eta_i t^{4-i}$$

"c" is a normalization constant calculated by  $c^{-1} = \sum \eta_i t^{4-i} \alpha_i$ . If we solve all the parameters above, we can draw the diagrams in the paper.

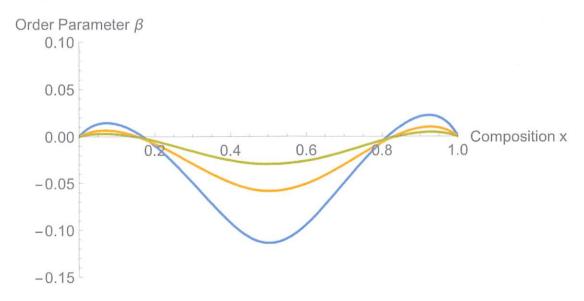


Each sub-index in the plot means the ith configuration. So the figure tells us that for type 1,2,3 when temperature increases, the ratio of each configuration increases. While for type 0 and 4, the trend is opposite.

For the order parameter, I used the equation 14 in the paper.

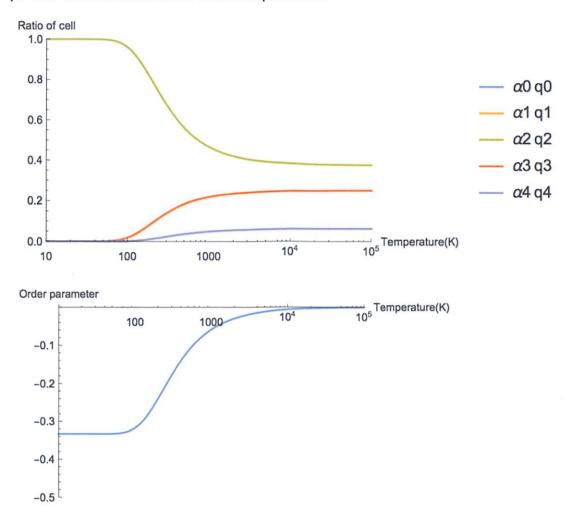
$$\beta = 1 - \frac{q_1 + 2q_2 + q_3}{x(1-x)}$$

However, the results of my calculation seems a little bit different from the paper's results.



Blue line corresponds to T=500K. Orange corresponds to T=1000K. Green corresponds to T=2000K. At very low x and very high x, order parameters seem to have positive values, indicating the alloy tends to form cluster at these compositions. I will discuss why there is a discrepancy here later.

For Fig 5, I split it into two figures for convenience. These are the results for composition x=0.5, which means for  $In_{0.5}Ga_{0.5}As$ . The only difference for these two plots is that it is assumed for fixed composition x.



We can see from the top diagram. When temperature increases, type 2 configuration starts decreasing, while type 1,3 and 0,4 are both increasing. As the temperature reaches very high value, the alloy tends to form cluster instead of having short-range ordering.

Now I discussed about why there is a little discrepancy in the order parameter plot. The primary reason comes from the strain energy. When I am using the equation in Taso's chapter, the total strain energy has already been simplified. The total energy's dependence on position of As in the tetrahedron, which is z, has only considered up to the second order. That's why the strain energy dependence on composition x is not completely resembles paper's results. And this later make an influence on the order parameter plot.

**b**)

The primary point in this paper is that III-V ternary alloys tend to have short range order instead of clustering. Traditionally, when we are discussing the III-V alloy, we used the virtual crystal approximation or assumed the atom positions are completely random. But experimentally, there are reports saying that there is short-range order.

The enthalpy of traditional strain energies is based on virtual crystal approximation, which is four times larger than the experimental values. To get a more accurate results, we can use different tetrahedron configurations to calculate the strain energies and then plug into the enthalpy. And we have to take both bond-length deviation and bond angle distortion into strain energy calculations.

Entropy is the primary difference for this configuration method. The strain energy is stored in the bonds between the nearest atom's bond. Writing down the free energy and Lagrange multiplier can give us the equilibrium configuration ratio. From Fig3, we can see that there is an ordering occurs when temperature increases. Take x=0.5 for instance. We can see type2 ratio is slightly increased, while type 0 and 4 decreases.

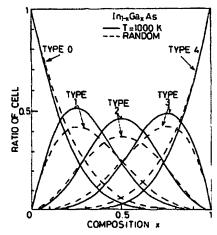


FIG. 3. Fractional values of five tetrahedron cells. Broken line: random arrangement, Solid line: at T = 1000 K for  $\ln_{1.0.8} \text{Ga}_1 \text{As}$ .

From the order parameter plot, we can see that as we increase the temperature, the parameter goes to negative value, which means there is ordering when temperature is increasing.

Alloy tends to order at low temperature since the entropy contribution is very small in the free energy. Enthalpy dominates and tends to have more order to minimize the energy. As temperature increases, the order becomes little. Basically,

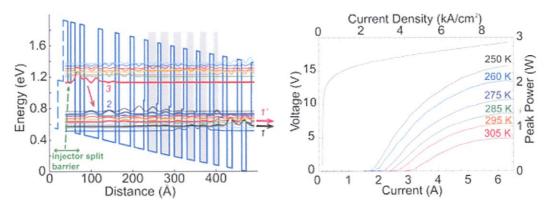
for all the alloys between two composite binary compounds, the order parameter is negative, which means they tend to have short range order.

From all these results, they concluded if there compositional fluctuation in the alloy, it will be suppressed in equilibrium state since fluctuation has larger strain energy. And the short range ordering is preferred instead of clustering.

Since tuning these alloy's composition can result in bandgap offset, a lot of research utilized these features to create optical devices. Using these alloys, researcher can create quantum wells in the growing process. Like the discussion in the class before, quantum well structure can enhance the carrier recombination (joint density of states). Either interband or intersubband optical devices had been developed based on these materials.

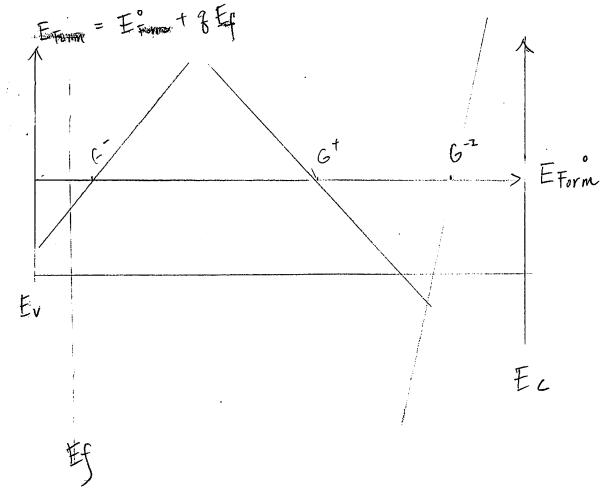
Here I found on the semiconductor today's example is quantum cascade laser (QCL). The first QCL experiment is conducted by Jerome Faist, Federico Capasso and the well-known co-inventer of MBE Alfred Cho in 1994. The first QCL was based AllnAs/GaInAs QWs on InP substrate. Within 20 years, QCL has been improved from cryogenic temperature to room temperature operation, and can reach power as high as Watt level.

The article is published at Applied Physics Letter, "High power Sb-free quantum cascade laser emitting at  $3.3\mu m$  above 350K", written by A. Bismuto, M. Beck and J. Faist. Their device active region consists of  $In_{0.72}Ga_{0.28}As$ ,  $In_{0.52}Al_{0.48}As$  and AlAs quantum well structures. Their uniqueness is that usually QCL's emission wavelength under  $3.6\mu m$  needs to incorporate Sb into the structure, but this material is not allowed for commercial users. Their new design can achieve comparable output power with Sb-based QCL. Generally, in order to make high efficiency QCL, researcher needs to design the injection and extraction superlattices in the device, here they used bound to continuum design. Composite binary alloys are suitable for this kind of application. They can achieve low threshold current of  $3.6kA/cm^2$  and slope efficiency of 600mW/A. And the laser can work at room temperature.



Right hand side is their active region design. Left hand side is the Power vs current curve.

Problem 4.4)



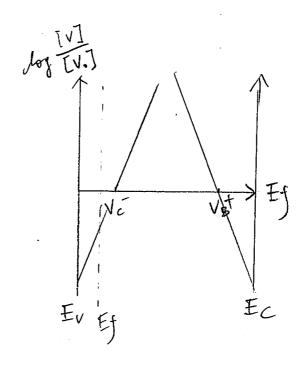
The charge state with the minimum formation energy should be the dominant state in the crystal. And G is a group I atom, which means doping this into II-V semiconductor should give us p-type crystal. So Ef should be near the volence band. As we can see from the above figure, G-2 state gives us the minimum energy. Therefore, G<sup>2</sup>-state is the majority.

Problem 4.4)

1) EForm = Eform + & Eform + & Form = Eform = Eform + & Eform = Eform + & Eform = Eform

The minimum formation energy occurs for VB+ state. Therefore, the majority is VB+.

 $\frac{1}{2} \sum_{i=1}^{n} \frac{1}{F_{i}} \sum_{j=1}^{n} \frac{1}{F_{$ 



From the argument in Sec. 7.1.5, we can draw number of charged states as left hand side And we know for Gatom doping is p-type. Fermi level should be near the valence band. We can that the intersection with Eff is higher for Vet state, which means Vet vacancy will dominate.

Problem 4.4)

Number of atom's charge states

Vacancy

Vacancy  $G = G + G - H^{\dagger}$ Some process  $G + e^{-} \rightarrow G^{-}$   $G = G - H^{\dagger}$   $G = G - H^{\dagger}$  G =

From the above plot, we can see that it is not possible for

6 atom to make huge influence on n-type side.

As we can see from the figure, Ef is near conduction band for n-type seniconductor. Even if there are some G atoms in this region, the preferred State is Gt state.

Hence, 6 atoms in n-type region wouldn't be trapped

a. So F atom acts as an acceptor in the crystal. The electron negativity of F is higher than C, which means it would grab electrons more Strongly than original Carons in the semiconductor. Hence, Fatoms will replace Catoms.

b. To determine whether I will segregate or not, we need to discuss the diffusivity From Eq. (7.10) in Rockett's book, we have  $\mathbb{P}_{\overline{T}} = \mathbb{D}_{q=0} + \mathbb{D}_{+1} \left( \frac{\mathbb{P}}{n_i} \right)$ 

 $D_G = D_{q=0} + D_{+1} \left( \frac{P}{n_i} \right) + D_{+2} \left( \frac{P}{n_i} \right)^{-1}$ 

# Problem 4.4)

- b. From the above two equations, we can see that diffusivity of G has second order dependence on doping concentration.

  Therefore, if all the other parameters are the same, G acoms have larger diffusivity. It is more likely for G to segregate to the surface than F atom.
  - c. If we want to use an atom as surfactant, the atom should have the ability to passivate dangling bonds at surface.

    Generally, these materials segregate strongly to the surface.

    Therefore, it's more likely to choose G atom as surfactant.

5)

a. no Gatoms. = only Hortons contributes as donors.

$$E_F - E_i = k_B T \ln \left( \frac{N_d}{n_i} \right)$$

Ef = 1.745eV above valence band.

b. [G]/[G₀]=e<sup>toT</sup> ≈ 2.5|×10|8

c. 
$$[G^{-2}]/[G^{-}]=e^{\frac{E_{1}^{2}-E_{G^{-2}}}{k_{B}}}\approx 275$$

Problem 4.4)

5.) d. 
$$[G_{total}] = [G_{0}] + [G_{1}] + [G^{2-}] = 9.8 \times 10^{16}$$
  
 $= [G_{0}](1 + 1.28 \times 10^{18} + 1.28 \times 10^{18} \times 140) = 9.8 \times 10^{16}$   
 $[G_{0}] = [A_{0}] + [A_$ 

e

Problem 4.5)

8)

7) 
$$Q_{GaInAs} = 0.57d \text{ nm}$$

$$Q_{GaInAs} = 0.57d \text{ nm}$$

$$Q_{GaAs} = 0.565 \text{ nm}$$

$$Q_{InP} = 0.587 \text{ nm}$$

$$f = \frac{0.489 - 0.572}{0.583} = 0.0256$$

$$V=0.29$$
  $\theta=\phi=60^{\circ}$    
From  $E_7.7.30$  in Rockett, we have  $\frac{h_c}{b}=\frac{1-\nu\cos^2c}{8\pi f(1+\nu)\cos\phi}$ ,   
 $T_0$  look for solution,  $l$  used mathematica to get numerical value.

$$\Rightarrow \frac{hc}{b} \approx 11.13$$

 $\alpha = 1$ 

As we increase the film thickness above critical thickness, the strain energy in the film will exceed the formation energy of dislocation, which means film will tend to form dislocation in order to minimize the energy. Introduction of dislocations into the interface can decrease the effective misfit in the film and substrate.

Problem 4.5)

a. 
$$Edis = \frac{Gb^2}{4\pi} \frac{1 - \nu \cos \theta}{1 - \nu} ln(\frac{\alpha h}{b})$$

Case (2) 60° partial dislocation =) 
$$\theta = 60^\circ = \cos^2 \theta = \frac{1}{4}$$

Folis

To give the maximum strain relief,
we need the largest Edis, which is
the Case 3. perfect screw dislocation.

b. The most likely to form is the one with the minimum Edis, which is the perfect edge dislocation.

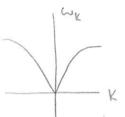
$$Nd = 1.1 \times 10^{15} cm^{-3}$$

trom Eq. 1. 16 in Rockett, we can get an approximation of the radius of dislocation effects on carrier. Assume  $\vec{b}$  and dislocation line are perpendicular.  $\Rightarrow \alpha = \frac{\pi}{2}$ 

$$\pi^{2}RNJ = \frac{f \sin \alpha}{a} \Rightarrow R = \sqrt{\frac{f}{a\pi NJ}}$$

$$\approx 2.1 \times 10^{-5} \text{ cm}$$

a. In a 10 orgstul sorething like o a 20 30 Ha occustic phonons, and the dispusion relation will lack like:



because there is one a one atom books. Right at K=0 there is a zero-energy mode called a Goldstone mode that corresponds with

the overall translation of the whole system.

K More generally, this and other Collistone modes armse from a broken continues symmetry. In the cax of phonons, the continues symmetry is translational, i.e. you can move the system in the x direction and everything looks exceeding the same. These make necessarily have a energy because the symmetry of space (translational) means that there is no preferred direction in which the System has higher or lower energy.

In a perfect semiconlatur crystal, in 3 dimensions, there could be more of these mades, one for each continues symmetry to roken. This amounts to phononi that represent the aprill translation of the crystal in any of 3 directions,

there is only I dimension, so = (Kat-Kin) & and b. For the 10 case: K;  $S(y) = \frac{1}{N} \left[ \sum_{i=0}^{N-1} e^{iqR_i} \right]^2$ ,  $R_i = 0$  defines the lattice points  $\sum_{i=0}^{N-1} e^{iq\alpha i} = \sum_{j=0}^{N-1} (e^{iq\alpha j})^{j} = g_{content} \text{ series} = \frac{1 - e^{iq\alpha N}}{1 - e^{iq\alpha}} = \frac{e^{iq\alpha N/2} (e^{iq\alpha N/2} - e^{iq\alpha N/2})}{e^{iq\alpha N/2} (e^{-iq\alpha N/2} - e^{iq\alpha N/2})}$ 

= eigaN/z (-Zi) sin(2aN/z) so, taking the mag:

$$S(2) = \frac{1}{N} \frac{\sin^2(\frac{N\alpha q}{z})}{\sin^2(\frac{qq}{z})} = |---|^2$$

C. A plot of this for N=10, 01 aq = 10 TT is attubed. From counting, there are 8 smull Peuks between each maxima, not counting the maxima.

A plot with N=100 is also attached, now the maximum peaks have amplitude 100.

In general, maxima happen when Nag/z = nTT and ag/z = mTT, where n, m = 0, ±1, ±2,... We need both to be satisfied, so:  $\frac{\alpha q}{z} = \frac{n}{N} \pi = m \pi$ 

So the maximum peak has amplitude N.

The Zeros in between the maxima comes when the numerature is 0:



The separation of minima is ag = 2TT - N

So from one maximum to the other there are 2TT - N

minimu, including the 2 maximum peals themselves, which happen also who the numeration = 6.

So in each period there are N minima, but one corresponds with, the main peak so there are really n-1 true minima. Then N-1 minima means N-Z maxima, so in total there will be N-Z Satellite peaks, not including the maxima peaks.

d. Plots of SCQ) for N=10 and N=100 CHZ attented, each with 3 randomly missing atoms,

For N=10, the maximum peak hight is ~5, which is much smaller than the 10 it started with. Also, now there are 4 smaller peaks between the main peaks, but they are pourly defined

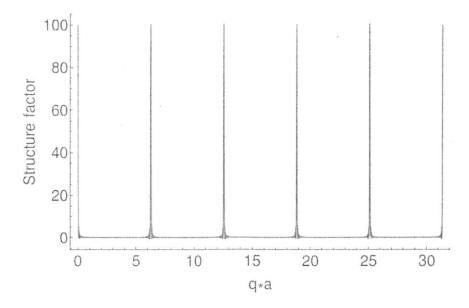
For N=100, the new peak height is around 95, As only 3/100 atoms were remard, this did not have such a large effect. The width is hard to estimate, but it seems to be about 0.05 = D(ga) which is similar to the aux with no defects.

In general diffraction experiments would not be so useful to get information about point defects because the partern is not so sensitive to defect if they have a fairly low density (as they normally do). Furthermore, even if they have a high density as in the first case, the diffaction pattern contains vary little information about the location of defects, although maybe you can extract owne information about the # of defuts,

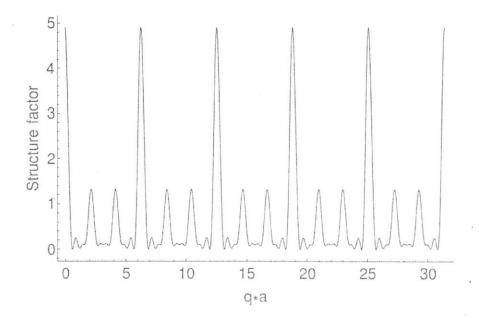
q\*a

Net-Prin

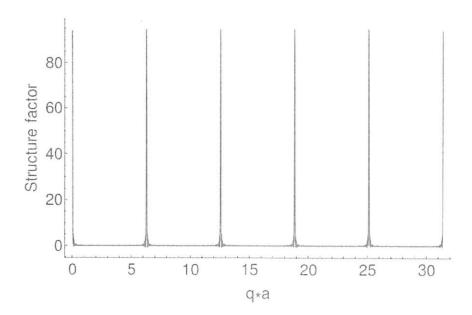
4.1c: Structure factor for a linear crystal with N=10.



4.1c: Structure factor for a linear crystal with N=100.



4.1d: Structure factor for a linear crystal with N = 10 but three random sites missing.



4.1d: Structure factor for a linear crystal with  $N=100\ \text{but}$  three random sites missing.

4.2)  $\alpha$ . At T=0, then should be no displacement, so  $S(\hat{q},T=0) = \frac{1}{N} \left| \sum_{j=1}^{N} e^{i\hat{q}\cdot\hat{R}_{j}} \right|^{2}$   $= \frac{1}{N} \left| \sum_{j=1}^{N} e^{i\hat{q}\cdot\hat{R}_{j}} \sum_{k=1}^{N} e^{i\hat{q}\cdot\hat{R}_{k}} \right| = \frac{1}{N} \exp\left\{ \sum_{j=1}^{N} \sum_{k=1}^{N} e^{i\hat{q}\cdot\hat{R}_{k}} \right|^{2}$ 

with the mapping  $\vec{A}_i \rightarrow \vec{R}_c + \vec{u}_i(t)$ ,  $S(\vec{Q},T) = \frac{1}{N} \sum_j e^{i\vec{q}_i \vec{R}_j + i\vec{q}_j \cdot \vec{u}_j(t)} \sum_k e^{i\vec{q}_i \cdot \vec{R}_k - i\vec{q}_j \cdot \vec{u}_k(t)}$ 

Now u; (+) fluctuates, but it fluctuates randomly, so we will be interested in some kind of average of the second term (eig. a. (+)).

This over S(q,T)= \ \ \ \ \ \ e^{iq.R\_j} \ e^{iq.u\_j} \ \ \ \ \ e^{iq.R\_k} \ e^{iq.u\_k} >

These averages are the same for every atom, because the thornal motion is random,

So we can take them out of the sums:  $S(\vec{q}, T) = \left[\frac{1}{N} \sum_{s} e^{i\vec{q} \cdot \vec{R}_{s}} \sum_{k} e^{i\vec{q} \cdot \vec{R}_{k}} \right] \langle e^{i\vec{q} \cdot \vec{u}} \rangle \langle e^{i\vec{q} \cdot \vec{u}} \rangle = S(\vec{q}, T = 0) \langle e^{i\vec{q} \cdot \vec{u}} \rangle \langle e^{i\vec{q} \cdot \vec{u}} \rangle$ 

This is not gute what the sheet has but everything works out in the end.

b. We will be expanding Leique > using a Taylor Series:

 $\langle e^{i\vec{z}\cdot\vec{u}}\rangle = \langle 1\pm i\vec{q}\cdot\vec{u}+\frac{(\pm i\vec{q}\cdot\vec{u})^2}{2} + ... \rangle = 1\pm i \langle \vec{q}\cdot\vec{u}\rangle - \frac{\langle \vec{q}\cdot\vec{u}\rangle^2}{2} \rangle$ 

This is useful because  $\vec{q} \cdot \vec{u}$  on average is 0, there is no preferred direction. This means we can approximate  $(e^{\pm i\vec{q} \cdot \vec{u}}) \approx 1 - ((\vec{q} \cdot \vec{u})^2)$  but in general  $e^* = 1 + x$ , so now  $(e^{\pm i\vec{q} \cdot \vec{u}}) \approx e^{-((\vec{q} \cdot \vec{u})^2)/2} = e^{2(1\vec{u}^2)/2}$ 

For atoms vibrating because of thermal noise, they approximately look hurmonic, so  $E = \frac{1}{2} \, \text{Kin}^2$ , where K is the spring constant, In terms of w, and M,

K= WOM, SO E = 1 MW347; and (E) = 1 MW022/1012>

From Harmodynamics, (E) = 1/2 KBT, SO NOW (1012) = KBT MW02

and so (e= iq: i) = e - q2koT/2mwoz Finally, plugging this in:

S(q,T)= S(\(\bar{q},T=0\)) e - q2 koT/2mu: - q2 koT/2mu: = \(\bar{q},T=0\)) e - q2 koT/mw2

C. With this structure factor, the first term SCQ, Too) will be the same

S(
$$\bar{q}$$
,  $T$ ) =  $\frac{1}{N} \frac{\sin^2(Naa)}{\sin^2(\frac{qq}{2})} e^{-(\frac{K_B T_{q^2}}{Mw_0^2})}$ 

Whereas before the higher order peaks all had the same amplitude, now the spectrum fulls off like a gassian because of the e-kat at/muse term. This makes sense because higher a corresponds to higher frequency x-rays that fits

The hurchengths between eich atom:

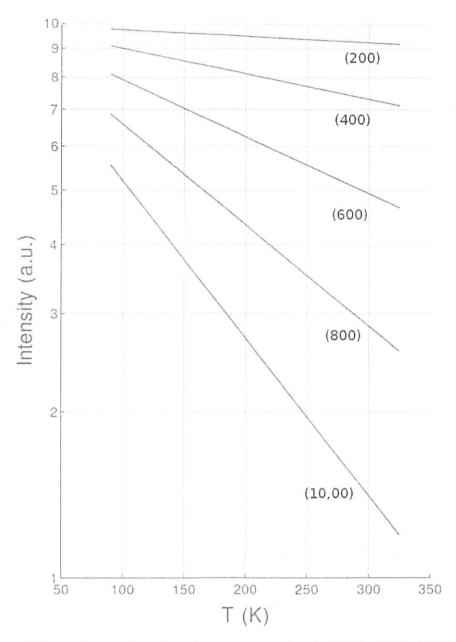
If each atom is displaced a little, the phase of light can change of Mannana the light will see low order even A; B; +4; E drustwally. This means the light will see low order even if the atoms only more a small distance from A;

At longer nurelenoths, the light is less susseptible to small charges in A:

No Aj lajtus

d. A plot of the peak intensity of the (200) (400) (600), and (10,00) peaks is attached. The parameters used to get the peaks on n=10, M=27 mp. W=0.34×10<sup>14</sup> rad/sec, a=0.4 nm. As expected, and shan in S(9,T)=S(9,0) e(KTg<sup>2</sup>), for the peaks or higher a the finite temperature has a larger effect. Furthermore, the temperature dependence is exponential which shows up as a line on the by scale plot. Quantitatively, the values compare decently well to the experimental data in Figure 1, and in particular the relationship is a straight line on the log plot which indicates exponential dependence, relationship is a straight line on the log plot which indicates exponential dependence, the agreement is not as good for low T, as presumably other factors become more important.

en The higher-of peaks show a strong temperature dependence, so in this sense massing their relative amplitudes could effectively measure the temperature. Of course it requires calibrating because it could be hard to get us, but that could not be too much of an issue. This would make best first of all for semiconductors with fainly small wo, or equivalently small "spring constants" between the atoms, as that would increase the effect T would have on the intensities. It also requires a very pure crystal, so that the peaks are not reduced so much from defects and the temperature dependence can be seen most clearly. Finally, for the same reason as wo, this would crystals with small as



4.2d: Diffraction peak intensity as a function of temperature, for the (200), (400), (600), (800), and (10,00) peaks. The parameters used for this are M=27\*mp,  $w0=0.34*10^14$  rad/sec, u=0.4 nm.

L1.3) a. In general there are 5 types of cells in a lattice of a III-V ternary alloy, such as Ini-x Oux As. In each the center abon is As, and there are 0,1,2,3 or 4 Ga atoms and 4,3,2,1, and 0 In atoms bounded to it. At any given composition there will be a different number of cells of each type. The # of cells of type i is given by

Notice, where N is the number of atoms total, it is the degeneracy of configuration i, and qi is the probability that configuration i appears. The degeneracy is needed because while there is only I way to form a type of cell there are Co unique was to form type 2 cells.

we want to find the ratio of cells of type i, so Noigi = digi which amounts to finding qi. If the atoms are distributed randomly, with no structure, then qi depends only on x, as the composition determines the most likely cell types. In this case, qi = x<sup>4-i</sup>(1-x)<sup>i</sup>, and this is used to plot digi for cash i as a function of composition, in Figure 3 as the dotted line.

The atoms are really not distributed randomly, however, because each crystal cell type feels a different amount of strain at different concentrations due to bond streeting and bond bending. This is modelled by assuming that at any x, the atoms lie on the planes of a virtual crystal, with lattice constant linearly interpolated from that of GaAs to that of InAs constant linearly interpolated from that of GaAs to that of InAs based on x. Each fell type has bonds that street different amounts, so can cell type has a different strain energy at a given x. This strain so cash cell type has a different strain energy at a given x. This strain so cash cell type has a different strain energy at a given x. This strain

To find the true cell ratios, the strain needs to be taken into account to strain mixing by writing a face energy function that takes into account the strain mixing enthulps, and the entopy associated with mixing;

F= N\[ di2\_i \( \xi\_i - N \) \( \xi\_t \) \( \( \xi\_t - \xi\_t \) \( \( \xi\_t - \xi\_t \) \( \xi\_t - \xi\_t \) \( \xi\_t - \xi\_t \)

To find the equilibrium  $Q_i$  values, F must be minimized. In the paper they use the method of Layrange multipliers and obtain  $Q_i = C N_i + \frac{1}{i}$ , where C is  $-\frac{1}{2} / K T$  the normalization constant  $C = \left( \sum_{i=1}^{n} N_i + \frac{1}{i} A_i \right)^{-1}$ ,  $N_i$  comes from the strain:  $Q_i = C$  and C is the positive solution to  $(1 \times N_i) + (3 - 4 \times N_i) + (3 - 6 \times N_i) + (1 - 4 \times N_i) + (3 - 4 \times N_i) + (3 - 6 \times N_i) + (3$ 

This soldion corres from a system of cyclins, 5 of the equations come from.

the Lagrance multipliers form: (for each i)

dF + a2i + b7i =0, where a and b are the Layrunge multipliers and

70=1, 71=3, 72=3, 74=1, 75=0.

The other two equations are normalization:  $\sum \alpha_i q_i = 1$ , and the constraint on the composition  $X = 20 + 3q_1 + 3q_2 + q_3$ .

The 7 unknowns are qo, q, q-2, qs, Qy, and a and b. Solving this system gives the solution above.

These as are used to plot the durk solid line in Figure 3, by ration of cell is = 2idi, at each x. Ornerally these depend on temperature, and in this case T=1000 K.

A reproduced Figure 3 is attached, showing the ratio of cell, diqi, as a function of x for each cell. The solid line corresponds to qi's derived from the thermodynamics and the dusted line corresponds to ai's derived from combinatorics and statistics, and the dusted line corresponds to ai's derived from combinatorics and statistics, and the amount of each cell in a crystal made up of a given composition,

The order purumeter B effectively measures the tendancy for citoms to alternate Ga, than In, in which one Bis negative. Therefore BLO implies some short runge order and B>O implies some clustering. In Figure H, that B<O always indicates that in GaAs there tends to be short runge order, instead of clustering. Furthermore, as T decreases B decreases, indicating more order. This makes sense as at lower temperatures there should be more order.

A reproduced Figure H is cattacked,

Finally, this same information is plotted in Figure 5, but now the temperature dependence is emphasized. All of the information is for x=0.5, so Ino.,  $\sigma$ ao,  $\sigma$  As. First, the order parameter  $\sigma$  is shown as a dashed line, and the value are shown on the left. As expected, at lover  $\tau$  the crystal becomes more ordered, but it flutters out at  $\sigma$  = - $\tau$ 3.

The ratio of cell is also shown for x=0.5 as solid lines, one for each type, and the values are on the right. At low temperatures the strain centhulps dominutes and type 2, with the steerin energy at x=0.5, dominutes. At higher temperatures enterpy becomes important and evalually dominutes.

A reproduced Figure 5 is attached.

b. The major point this paper present is that thrown a thermody namic argument considering the strain enthulps and mixing entropy. II - V compand semiconductors prefer to order instead of cluster over a short range. The clustering argument makes intuitive sense: in general the total strain energy can be minimized if instead of lazing in planes of a virtual crystal, the atoms cluster into like regions where the strain can relax. This is further supported by the evidence that clustering like this occurs on a much scopic scale, what the authors show however, is that this clusting is not that happens on a nicroscopic scale. Instead it is energetically preferable averall for there to be some short range order, instead of clostoing. This can be understood as microscopically, the energy cost of firming clusters overall is higher than order because of the interactions near the edges of the clusters.

500d: 20

This paper discussed III-V ternary alloys in general, but used InGaAs for all of the examples. From 'Semiconductor Today,' examples of recent applications of InGaAs that people are interested in include quantum wells for quantum information processing, high speed photodetectors, and high quality MOSFETs. In each of these InGaAs is the active material, and therefore understanding the microscopic ordering and the effect of strain is important to optimize the material for applications.

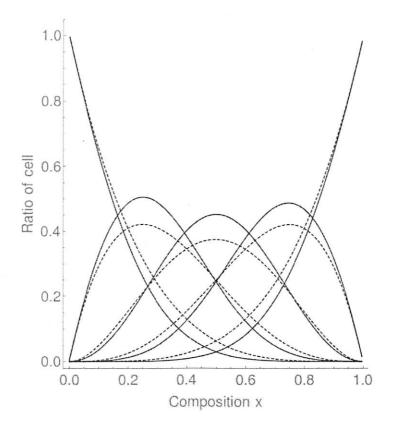
Net-Pri

At the end of 2015 Bechtold et al (*Nature Physics*, 11, 1005-1008 (2015)) used InGaAs quantum dots on GaAs to study trapped single electrons, and in particular the mechanisms of loss of quantum information. One of the mechanisms they identified, in fact, was strain that creates electric fields on a microscopic scale. By using a (strong) magnetic field, they were able to reduce the effect of this and other loss mechanisms, and increase the lifetime of quantum information. They present this research as a step towards InGaAs-based quantum computers.

Near the middle of 2015, Semiconductor Today reported that Marktech launched a high speed photodetector using InGaAs. The photodetectors operate from 0.9-1.7  $\mu$ m, which is good for optical communications. They claim that the photodetectors can support high data rates and low dark current, increasing the signal to noise ratio.

Finally, at the beginning of 2015 Kim et al (*IEEE Electron Device Letters*, (2015)) demonstrated an InGaAs MOSFET with a good sub-threshold swing, transconductance, and on-current. The device was made with InGaAs and InP, with an InGaAs channel. The devices were grown with MBE.





Net-Prin

Figure 3: Ratio of cell as a function of composition. The solid line is calculated taking into account strain energy and entropy at 1000 K, the dashed line is calculated assuming the atoms are distributed at random.

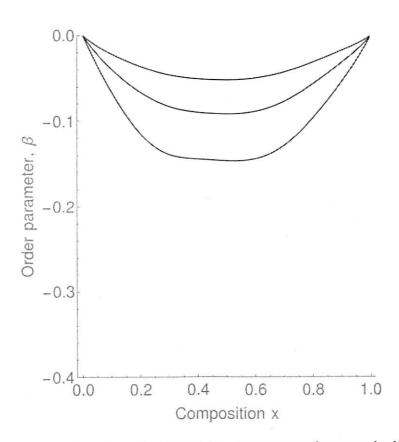


Figure 4: Order parameter as a function of composition. From top to bottom, the lines are calculated for  $2000~\rm{K},\,1000\rm{K},\,and\,500~\rm{K}.$ 

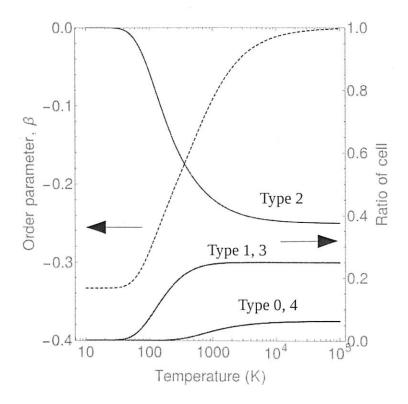


Figure 5: Order parameter and ratio of cell as a function of temperature, for x = 0.5. The dotted line is the order parameter and the solid lines are the ratio of cell for each type of cell.

4.4) 1. G is an acceptor because it is in group I, so it will pull down the fermi level to around the shullow level for G.

i. Most of the o atoms will be in the [-1 state,] as the Fermi energy will be slightly above of so electrons will tend to ionize or about once. ii. Ve vaccincies will be neutrall as they are too deep and will therefore not be ionized.

VR vaccances will be charged + 1 as the Fermi level is below their energy, so they will not be neutralized.

2. Ve vacancies will be more common who the material is doped with 6 (acceptures). The uncharged vacancy concentration generally does not charge too much with Ferni level, but at the same time

$$\frac{\left[V_{o}^{+}\right]}{\left[V_{o}^{+}\right]} = e^{\left(E_{f}-E_{+}\right)/kT}$$

$$\frac{\left[V_{o}^{-}\right]}{\left[V_{o}^{-}\right]} = \left[\frac{\left[V_{o}^{-}\right]}{\left[V_{o}^{-}\right]} = \left[\frac{\left[V_{o}^{-}\right]}{\left[V_{o}^{-}\right]}\right]$$

Es is close to the valence band, so [Vat] will be very high while [Vi] will be very small. While there may not be very many neutral vaccancies, then, there will be many changed Va vaccancies

- 3. On the n side, doped heavily with H, the Farmi level will be close to the conduction band, so any residual G atoms will be in the G2-state. Most likely, these will ad as traps, because doubly charged is my are often traps as they can take a minority carrier (hote), while still repelling e because the charge is now-1.
  - H. a. If F is an acceptor, then it must replace the group V atom B primurity. In that case there would be I less electron than before, making it an acceptor.
    - by Family have a greater tendancy to go to the surface because it has a larger radius than Cr. and the larger abon counts to minimize its strain energy more, which can happen on the surface.
    - C. [F] would be more likely to work as a surfactant because it has a larger size, so it would go to the surface, and also it is are grop away from the III-II luttice, which is desirable.

5. a. If there are no G atoms, 
$$N_a=0$$
,  $N_d=2\times10^{17}$  cm<sup>-3</sup>, so  $E_f=E_i+kT\ln\left(\frac{N_d}{n_i}\right)=\boxed{1.24\text{ eV}}$  from valence band

c. 
$$\left[6^{-2}\right] = \left[E_{f} - E_{\sigma_{z}}\right] / kT = \left[232\right]$$

d. There will be busically no neutral or citims, to good approximation, so

$$[G^{2}] + [G^{-1}] = 9.8 \times 10^{16} \text{ cm}^{-3}, \quad [G^{-2}] = 232$$

$$= > [G^{-1}](1+232) = 9.8 \times 10^{16} \text{ cm}^{-3} \Rightarrow [G^{-1}] = 4.21 \times 10^{14} \text{ cm}^{-3}$$

$$[G^{-2}] = [G^{-1}]232 = 9.76 \times 10^{16} \text{ cm}^{-3}$$

$$[G^{-1}] = [G^{-1}] = [G^{-1}]232 = 9.76 \times 10^{16} \text{ cm}^{-3}$$

e. From cand d. 4.21 x 10 H cm<sup>-3</sup> G atoms have accepted 1 eT, and 9.76 x 10 K cm<sup>-3</sup> have accepted 2 eT, so:  $E_E = E_i + kT \ln \left( \frac{N_0 + 2[G^2-] + [G-]}{1 + [G-]} \right) = 1.1H eV$  or an error of 0.1 eV, which is not so bad. No

C. First we read  $[V_o]: [V_o] = Ne^{\Delta S_{old}/K_0} e^{-\Delta E_{old}/K_0}$ ,

Assuming  $\Delta S_{vio} = 1.1 \, K_0 \, [V_o^8] = 9.48 \times 10^{11} \, cm^{-3} \, [V_o^c] = 2.38 \times 10^{12} \, cm^{-3}$   $[V_o^8] = [V_o^8] e^{-(E_f - E_o^4)/K_T} \, E_o^4 = 1.3 \, eV - 0.45 \, eV_o \, S_0 \, [V_o^8] = 5.45 \times 10^{9} \, cm^{-3}$   $[V_o^6] = [V_o^6] e^{(E_f - E_o - )/K_T} = 7.19 \times 10^{10} \, cm^{-3}$   $[V_o^6] = [V_o^8] = [V_o^8] = [0.53 \times 10^{11} \, cm^{-3}] \, [V_o^6] = [0.53 \times 10^{11} \, cm^{-3}]$ 



4.5)

7. The misfit  $f = |\alpha_s - \alpha_s|$  For GaAs: f = 0.0124FUT INP: (F=0,0256)

8. For a Co. type mister dislocation 0=0= Co., and the critical  $h_{1}/b = \frac{1 - v \cos^{2}\theta}{8\pi f(1+v)\cos\theta} \ln\left(\frac{dh_{2}}{b}\right) \cdot \text{numerically as}$ thick ress can be fund by soling

h= 11,11

- a. Distactions would be introduced into the film by some form of dislocation multiplication if the thickness is much greater than the critical thickness Generally the dislocation multiplication is enabled by threading distourious, one example of this is the Founk-Bed mechanism. In this case a misfit dislocation is pinned by 2 throwing segments, and as it goods the mistit dislocation Separates out and creates a new dislocation. This happens when Here is large stress, which is the case for for for for
  - 10, a, Bother these 3, a perfect edge distocution provides the maximum Steen relief for the same dislocation line energy. This can be seen eccuse, equivo for an edge O=U

    if the dislocation energy

    stain relief

    b. A 60° mish + dislocation is most kely

    edge dislocations are the most energy

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    if the disloc because, equivelently for the same strain relief Edisa I-vcosio, So for an edge 0=0° and Edis is me if the dislocation energy is the same, an edge dislocation make the

the dislocal star relief.

3. A 60° misht dislocation is most very cause on good plans who character with a character with a character of the dislocal of the character of the c the a sum relief.

A 60° misht dislocation are the most comes comes on so splans him dislocation are the most comes comes of the smaller dislocation which we have a summary that seems that we have the same of the same continued and so that we have the same continued and seems are the most comes comes comes and the same continued and seems are the most comes comes and the same comes comes and the same comes comes and the same comes comes comes comes and the same comes co A 60° miss

2da dislocations are

cross on 80013 plans has

dislocation

Can ham are

On 8



Sanjeer Kolli ECE5570HW4

#1

PROB1

a) Goldstone modes are slow long range in fluctuations in a given order parameter. They originate from a non-barrier transition, i.e. there is nownergy cost for the fluctuations. A symmetric phase at high temperature separates into two asymmetric phases to example in semiconductors is the existence of spin waves

 $\frac{1}{N} \frac{2}{(2 - e^{iqa} - e^{-iqa})}$   $\frac{1}{N} \frac{2(1 - \cos qaN)}{2(1 - \cos qa)}$ 

 $= 1 \frac{\sin^2(9aU)}{\sin^2(9aQ)}$ 

ECESS JOHW 4 Sanjeer Kolli PROB I cont.

#20

C) 10+

Satellite peaks = 8 (N-2)

Max height = 100

Sin (9aN)=0

qaN=TT

9a = 24 indicates Nways to get Zeros

(N satellite peaks

S(a) = N (Singal) 2 S(aa) = 2 (Singal) Nsingal - 1 Singal Singal

lim 1 (Singal) = //N/2 N/ Sinzga Sinzga N/N/2 N/ Sinzga

## Surjeer Kulli ELESS 10HW4

#3

PROB1 conti

Deak height and width for N-100 is roughly to some No, when detects are low in concentration they have only minor effects on diffraction experiments.

FGF NZ e 19/17+ 4:(+) = 1, Z; e 19 ( e 19 (3t)) To Zie 19 Fi Eltigia) = \ Zje of e z (liq. uj)  $S(q) = \frac{1}{N} \left\{ \sum_{i \in [q, \overline{q}]} e^{\frac{i}{2} \left( (\overline{q}, \overline{q}, \overline{q})^{2} \right)} e^{\frac{i}{2} \left( (\overline{q}, \overline{q}, \overline{q})^{2} \right)} \right\}$   $= \frac{1}{N} \left( \sum_{i \in [q, \overline{q}]} e^{\frac{i}{2} \left( (\overline{q}, \overline{q}, \overline{q})^{2} \right)} e^{\frac{i}{2} \left( (\overline{q}, \overline{q}, \overline{q})^{2} \right)} \right)$ = N Zeigli-10, 11 et (19.0,) 2 (1-) q. 0, )2) = 5 (9, TI=0) . Tike 19 5 (e) 9 un) = S(q, T=6) . Eig(4; -4)

Sanjeer Kolli

ELESS70 HW4

44

PROB2 cont.

b) (e i g = (vj(t) - VK(t)) = (1/19 = (vj(t) - VK(t)) = - Usek dx2 - Cu) = 2 Kdx2)

- KBT - Cdx2) - CBT 17

=e=(ZKOT)92

K= WO K= WOM

= (-KBTgZ)

C) S(q) = 1 Sin Waq e (- KBT q2)

The Debye Waller factor decreases the intensity of higher order peaks. Yes this makes intuitive Sense higheroider peaks are more afterted by fluctuating

d) on plats section

e) Yes one could use this temperature dependence as athermometer for a crystal. Semiconductors with large masses and high vibrational frequencies would allow for a slow decay for easy observation.

Sanjeernoll

## ECESS/0111/4

#5

PROB3

x=4 x2=6 x3=4 x4  $\alpha$ )  $\alpha = 1$  $q_0 = (1-x)^2 \quad q_1 = x(1-x)^3 \quad q_2 = x^2(1-x)^2 \quad q_3 = x^3(1-x) \quad q_4 = x^4$ 

For Random case these quantities by just Statistical entropic number of states.

For catculating strain energy of tetrahedra

Ustr + Ubre Combination of benefitretch Strain
Ustri 4 bonds to consider per tetracheda

Ubne = ZZZ Ubndij 6 bending anglesto consider

Ustri=  $\frac{3}{8} \alpha_i \left(\frac{di^2 - di_{i,0}}{di_{i,0}^2}\right)^2$  Usho,  $ij = \frac{3}{8} \frac{\beta_i + \beta_j}{2} \left(\frac{di \cdot dj - di_{i,0}}{di_{i,0}^2}\right)$ 

Un was calculated for each tetrahedratype as a function of global composition X.

Then minimizing free energy resulted in finding equilibrium q values with lagrange multipliers.

4i - CM; ty-1 N; represents Bottzmann distribution as a function of strain energy (1-4x) Not + (3-4x) Nt + (3-6x) Nzt ?. e ci/kT + (1-4x) Nzt + x Ny=0 L is normalized time. t represents inter type relationships Sanjeer Kolli

ECBS578

#60

PROB3 cont.

B represents order parameter and is colculated

B=1-91+292+93 after considering A-B pairs in a

A(1-x) given tetrahedron

regatives represents forvoring of

AB being together ratherthan

A-A or BJ-B.

With all these quantities Figures 3-5 could be recreated (Results shown on attached graphs)

- b) The deposition of ITT-V ternary alloys shows that ordering is pretered over clustering this is because fetrahedra in the Zin-Blense structure further from the average composition have higher strain energy. The reduction in strain energy due to long range ordering of the average composition tetrahedra is not as much of an effect at higher temperatures due to the prefence of a pright entropy system
- PHEMI based MMIC for communications Al Gasts PHEMT based MMIC for communications In GaAs lop loyer for 4+ multilayer Solar cells InGaP Al (nasb Infrared Optical Devices In Gasb high mobility ochennels for CMOS enhancement Red LEDS / Solar Cells

  DH BT > 700 GHz power gain alosto

  HBT High Power Devices Ga Assb GaPSb IN ASP the to detectors at long wavelengths In PSb Mid Infrared Photodetectors INASSB High mobility transistor sharmels

Sanjeer Kolli PROB4

ELES 570 HW4

#7

1) i) Charge balance (n+G=P) Nove = Ex-Ex)/KT No e (Ex-Ex)/KT = NG e F-EV)/KT E== 0.015

Up is mistly to because the pecupation state 15 above the frerm fevel and unoccupied

Presponds to 11 charge. Vc is mostly Preutral because Vc is above Fermi level 1.3 3.47 70.2 Jo.1 and unoscupied corresponds to neutral 0.13 70.15 Charac.

2) VB is were common because the manhiety with the vacancies. instead of taking from the valence band.

3) Traps because recombination centers would require an electron hole pair the G atoms would be likely doubly negatively charged acting as an electroni sink preventing recombination.

4) a) B sites 6) Gove to its multiple charge states within the gap

ECES570HW4 # \ Sanjeer Kolli PROB4 cont. 5) a) E= 0.65 eV + (8.617 × 10-5) (30010) (1 ~ (1×100)) = [1.245eV] above valence bandedge b) [G-] = (1.245-.15)(8.617 40.5)(300K) = 2,5 ×10 +8 c)  $\frac{[G^2]}{[G]} = e^{(1.245 - 1.10)[8.617 \times 10^{-5}](300k)}$ [Go] +. 2.5 × 10 [Go] + 273 (2.5 × 1016) [Go] = 9.8 × 1016 274/7.540 / 100 00 100 / 1507 = 1.4 X10 cm [G<sup>2</sup>]= 3,58 × 10<sup>14</sup> cm<sup>-3</sup> [G<sup>2</sup>]= 9,76 × 10<sup>16</sup> cm<sup>-3</sup>

e) Ex= 0.65 eV + (8.617 x 10 x/x) 300K) (In ((2x10<sup>17</sup>) = (1.956 x 10<sup>17</sup>))/2x10<sup>7</sup>)) = 0.65 + .514 = 1.164 eV above valence bandedge / Afferror = .081 eV Sanjeer Kolli ECES 570HW4

#19

PROB 4 cont

[Va] = Ne (ASVID/KB) - A EVAC/KBT

[Va] = e (E\_F - EVAL) / KBT

[Va] = Ne (ASVID/KB) - A EVAC, B/KBT

[VB] = e (EVST - E\_F)/KBT

[VB] = e (EVST - E\_F)/KBT

PROBS

7) 
$$f = \frac{572 - .565}{.565} = .0124$$

Gats
 $f = \frac{.572 - .587}{.587} = -.0256$ 

8) Eel = FEdis

$$\frac{2G(1+V)f^{2}h - fGB^{2} - V\cos^{2}(\theta)\ln(\alpha h)}{(1-V)}$$

hc/b 1-2050 1-(29)(cos 68) = 4,64 In(oi he/b) 8TT f (HV) cos\$ = 8T(0124)(1+,29) cos (60°)

Sanjeerkolli

ECESS 70HW -1

#100

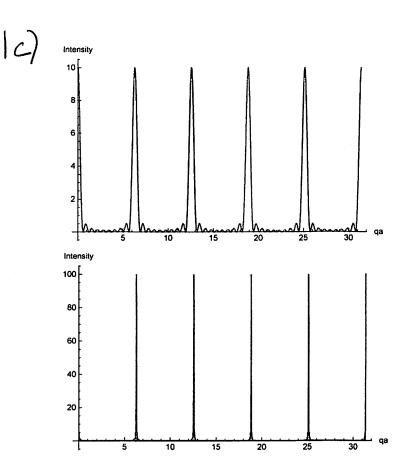
PROB Scenti

Threading distocation segments are the most common way of introducing distocations past the critical threkness. This happens by extension of existing distocations to meruly forming surfaces.

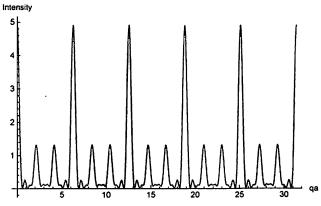
10) a) The perfect edge dislocation

b) The 600 partial dislocation be caused it is actually possible totorm (Burger's is inglide plane) and it releases more energy than the screw dislocation.

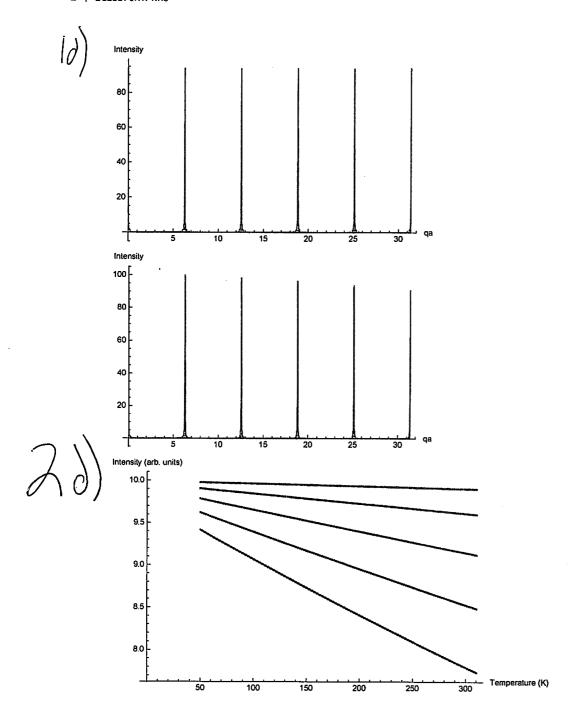
11)  $R = \sqrt{\frac{f}{a \pi N}} = \sqrt{(512)(\pi)(1+xi)^{15}(-3)} = 711.3 \text{ nm}$ 



 $\begin{array}{l} \mbox{vacatestruct} [n_{\tt}, j_{\tt}, k_{\tt}, l_{\tt}] := \\ \mbox{$1/n \star (Abs[(Sum[E^(I \star x \star a), \{a, 1, j\}] + Sum[E^(I \star x \star a), \{a, j + 2, k\}] + \\ \mbox{$Sum[E^(I \star x \star a), \{a, k + 2, 1\}] + Sum[E^(I \star x \star a), \{a, 1 + 2, n\}])])^2;} \end{array}$ 



10)



```
mp = \text{randomqs} = \text{Plot}[\{(1-x)^4, 4*x*(1-x)^3, 6*x^2*(1-x)^2, 4*x^3*(1-x), x^4\},
                     \{x, 0, 1\}, PlotRange \rightarrow All, PlotLegends \rightarrow {"Random"}, AxesLabel \rightarrow
                        {"Fraction of atom B", "Ratio of Cell"}, PlotStyle → {{Black, Dashed}}]
               Ratio of Cell
                  1.0
                  0.8
                 0.6
Out[274]::.
                                                                                                                                                           - Random
                  0.4
                  0.2
                                                                                                                 Fraction of atom B
  m(13) = Solve[4.614 * Log[x] - x == 0, x]
\{\{x \to 1.33576\}, \{x \to 11.1097\}\}
              \alphaGaAs = 41.19;
              \betaGaAs = 8.95;
              \alpha InAs = 35.18;
              \betaInAs = 5.50; aGaAs = 5.6533*^-10;
              alnAs = 6.0584*^-10; dGaAs0 = \sqrt{3} / 4 * aGaAs; dlnAs0 = \sqrt{3} / 4 * alnAs;
              aVC[x_] := ((x) * aGaAs + (1 - x) * aInAs);
              thetaT = 2 * ArcTan[\sqrt{2}];
 m(453) = dGaAs3[x_] := ((aVC[x]/4-z3)^2+aVC[x]^2/8)^0.5;
              dInAs3[x_] := (aVC[x]/4+z3)^2+aVC[x]^2/8)^0.5;
              cosGaAsGa3[x_] := (aVC[x]^2/2 - 2 * dGaAs3[x]^2) / (2 * dGaAs3[x]^2);
              cosInAsIn3[x_] := (aVC[x]^2/2 - 2 * dInAs3[x]^2) / (2 * dInAs3[x]^2);
              alttetstrain5050[x_] := 3/4 * \alpha GaAs * (dGaAs3[x]^2 - dGaAs0^2)^2/dGaAs0^2 +
                       3/4 * \alpha InAs * (dInAs3[x]^2 - dInAs0^2)^2/dInAs0^2 + 3/4 * \beta GaAs *
                           (dGaAs3[x]^2 * cosGaAsGa3[x]^2 - dGaAs0^2 * Cos[thetaT]^2)^2/dGaAs0^2 + 3/4 *
                          \betaInAs * (dInAs3[x]^2 * cosInAsIn3[x]^2 - dInAs0^2 * Cos[thetaT]^2)^2 / dInAs0^2;
in[468] = tetstrain5050solver[x_] :=
                 alttetstrain5050[x] /. FindRoot[D[alttetstrain5050[x], z3], {z3, 0}][[1]]
m_1 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 10000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 1000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 100000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 10000 = 100
l_{0130} = tetstrain0100[x_] := 3/2 * \alpha InAs * (3/16 * aVC[x]^2 - dInAs0^2)^2/dInAs0^2;
```

```
a_{1020} = ustr2575[x_] := 9 / 8 * \alpha InAs * (dInAs[x]^2 - dInAs0^2)^2 / dInAs0^2 +
          3 / 8 * \alpha GaAs * (dGaAs[x]^2 - dGaAs0^2)^2/dGaAs0^2;
     dInAs[x_] := \sqrt{\left(aVC[x] / 2 * \sqrt{2/3}\right)^2 + \left(aVC[x] / 4 / \sqrt{3} + z1\right)^2};
      dGaAs[x_] := \sqrt{3} / 4 * aVC[x] - z1;
      thetaT = 2 * ArcTan \left[ \sqrt{2} \right];
      tetredge[x] := aVC[x] /\sqrt{2};
      ubnd2575[x] := 9/4 * (\beta GaAs + \beta InAs)/2 *
           (dInAs[x] * dGaAs[x] * cosGaAsIn[x]^2 - dInAs0 * dGaAs0 * Cos[thetaT]^2)^2/dInAs0/
            dGaAs0 + 9 / 4 * \beta InAs *
           (dInAs[x]^2 * cosInAsIn[x]^2 - dInAs0^2 * Cos[thetaT]^2)^2 / dInAs0^2;
      tetstrain2575[x] := ustr2575[x] + ubnd2575[x];
     cosGaAsIn[x_] :=
         (tetredge[x]^2 - dGaAs[x]^2 - dInAs[x]^2) / (2 * dGaAs[x] * dInAs[x]);
     cosInAsIn[x_] := (tetredge[x]^2 - 2 * dInAs[x]^2) / (2 * dInAs[x]^2);
     tetstrain2575solver[x_] :=
        tetstrain2575[x] /. FindRoot[D[tetstrain2575[x], z1], {z1, 0}][[1]];
     ustr7525[x_] := 3 / 8 * \alpha InAs * (dInAs2[x]^2 - dInAs0^2)^2 / dInAs0^2 +
         9 / 8 * \alpha GaAs * (dGaAs2[x]^2 - dGaAs0^2)^2 / dGaAs0^2;
     dGaAs2[x_] := \sqrt{\left(aVC[x]/2 * \sqrt{2/3}\right)^2 + \left(aVC[x]/4/\sqrt{3} + z^2\right)^2};
     dInAs2[x_] := \sqrt{3} / 4 * aVC[x] - z2;
     tetredge[x] := aVC[x] /\sqrt{2};
     ubnd7525[x_] := 9/4 * (\beta GaAs + \beta InAs)/2 *
           (dInAs2[x] * dGaAs2[x] * cosGaAsIn2[x]^2 - dInAs0 * dGaAs0 * Cos[thetaT]^2)^2/
             dInAsO / dGaAsO + 9 / 4 * \beta GaAs *
            \left( dGaAs2[x]^2 + cosGaAsGa2[x]^2 - dGaAs0^2 + Cos[thetaT]^2 \right)^2 / dGaAs0^2; 
     tetstrain7525[x] := ustr7525[x] + ubnd7525[x];
     cosGaAsIn2[x_] :=
        (tetredge[x]^2 - dGaAs2[x]^2 - dInAs2[x]^2) / (2 * dGaAs2[x] * dInAs2[x]);
     cosGaAsGa2[x_] := (tetredge[x]^2 - 2 * dGaAs2[x]^2) / (2 * dGaAs2[x]^2);
     tetstrain7525solver[x ] :=
        tetstrain7525[x] /. FindRoot[D[tetstrain7525[x], z2], {z2, 0}][[1]];
```

```
m(184) = p1 = Plot[6.02*^23/4186*tetstrain0100[x], {x, 0, 1}, PlotRange <math>\rightarrow \{\{0, 1\}, \{0, 15\}\}, \{0, 15\}\}
                  AxesLabel → {"Composition x", "Strain Energy (kcal/mol)"}];
            p2 = Plot[6.02*^23/4186*tetstrain2575solver[x],
                  \{x, 0, 1\}, PlotRange \rightarrow \{\{0, 1\}, \{0, 15\}\}\};
            p3 = Plot[6.02*^23/4186*tetstrain5050solver[x],
                  \{x, 0, 1\}, PlotRange \rightarrow \{\{0, 1\}, \{0, 15\}\}\};
             p5 = Plot[6.02*^23/4186*tetstrain1000[x], {x, 0, 1}, PlotRange <math>\rightarrow \{\{0, 1\}, \{0, 15\}\}\};
            p4 = Plot[6.02*^23 / 4186 * tetstrain7525solver[x],
                  \{x, 0, 1\}, PlotRange \rightarrow \{\{0, 1\}, \{0, 15\}\}\};
             Show[{p1, p2, p3, p4, p5}]
                                                                                                                                               Fig Z from paper
             Strain Energy (kcal/mol)
                       14
Out-tout-
                                                                                                                            Composition x
 in[464] = tsolver[x_, temp_] :=
                  t /. Solve [ \{(1-x) * E^{(-tetstrain1000[x] / (1.38*^-23) / temp) * t^4 + (1.38*^-23
                                 (3-4*x)*E^{(-tetstrain7525solver[x]/(1.38*^{-23})/temp)*t^3+
                                 (3-6*x)*E^{(-tetstrain5050solver[x]/(1.38*^-23)/temp)*t^2+
                                 (1-4*x)*E^{-tetstrain2575}solver[x]/(1.38*^{-23})/temp)*t-
                                 x * E^{(-tetstrain0100[x] / (1.38*^-23) / temp)} = 0, t > 0, t | [[1]];
 m(405) = constant[x_, temp_] :=
                  (E^{(-tetstrain1000[x]/(1.38*^-23)/temp)*tsolver[x, temp]^4+
                         E^{(-\text{tetstrain}7525\text{solver}[x]/(1.38*^-23)/\text{temp})} * tsolver[x, temp]^3 * 4 +
                         E^{(-tetstrain5050solver[x]/(1.38*^-23)/temp)} * tsolver[x, temp]^2 * 6 +
                         E^{(-tetstrain2575solver[x]/(1.38*^-23)/temp)} *tsolver[x, temp] *4+
                         E^{(-\text{tetstrain0100}[x]/(1.38*^{-23})/\text{temp}))^{-1}}
 m(400)... q0[x_, temp_] :=
                  constant[x, temp] *E^(-tetstrain1000[x] / (1.38*^-23) / temp) *tsolver[x, temp]^4;
             q1[x_, temp_] := constant[x, temp] *
                     E^{(-\text{tetstrain7525solver}[x]/(1.38*^-23)/\text{temp}) * \text{tsolver}[x, \text{temp}]^3;
             q2[x_{,temp}] := constant[x, temp] *E^(-tetstrain5050solver[x]/(1.38*^-23)/temp) *
                     tsolver[x, temp] ^2;
             q3[x_{,temp_{,i}} := constant[x, temp] *E^(-tetstrain2575solver[x] / (1.38*^-23) / temp) *
                     tsolver[x, temp];
             q4[x_{,temp}] := constant[x, temp] *E^(-tetstrain0100[x]/(1.38*^-23)/temp);
```

```
inputs constant[x_, temp_] :=
        (E^{(-tetstrain1000[x]/(1.38*^-23)/temp)*tsolver[x, temp]^4+
            E^{-1} (-tetstrain7525solver[x] / (1.38*^-23) / temp) * tsolver[x, temp] ^3 * 4 +
           E^{(-tetstrain5050solver[x]/(1.38*^-23)/temp)} * tsolver[x, temp]^2 * 6 +
           E^{-tetstrain2575solver[x]/(1.38*^-23)/temp)*tsolver[x, temp]*4+
           E^{(-\text{tetstrain}0100[x]/(1.38*^{-23})/\text{temp}))^{-1}}
in[50] = q0[x_, temp_] :=
        constant[x, temp] *E^(-tetstrain1000[x] / (1.38*^-23) / temp) *tsolver[x, temp]^4;
     q1[x_, temp_] := constant[x, temp] *
         E^{(-tetstrain7525solver[x]/(1.38*^-23)/temp)*tsolver[x, temp]^3;
     q2[x_{,temp}] := constant[x, temp] *E^(-tetstrain5050solver[x]/(1.38*^-23)/temp) *
         tsolver[x, temp] ^2;
     q3[x_{temp}] := constant[x, temp] * E^(-tetstrain2575solver[x] / (1.38*^-23) / temp) *
         tsolver[x, temp];
     q4[x_{,temp}] := constant[x, temp] *E^(-tetstrain0100[x]/(1.38*^-23)/temp);
messa weightedqs = Plot[
        \{q0[x, 1000], 4*q1[x, 1000], 6*q2[x, 1000], 4*q3[x, 1000], q4[x, 1000]\}, \{x, 0, 1\},
        PlotStyle \rightarrow {{Black, Thick}}, PlotLegends \rightarrow {"In(1-x)Ga(x)As at 1000 K"}]
     1.0
     0.8
     0.6
Out ob!=
                                                               In(1-x)Ga(x)As at 1000 K
     0.4
     0.2
in[66]: Show[{randomqs, weightedqs}]
                                                                     Fig 3 from Paper
     Ratio of Cell
      1.0
      0.8
                                                                            --- Random
      0.6
Out60le

    In(1-x)Ga(x)As at 1000 K

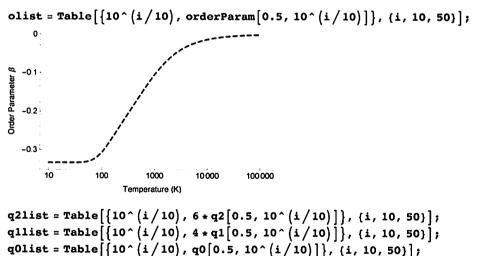
      0.4
      0.2
                                                             Fraction of atom B
```

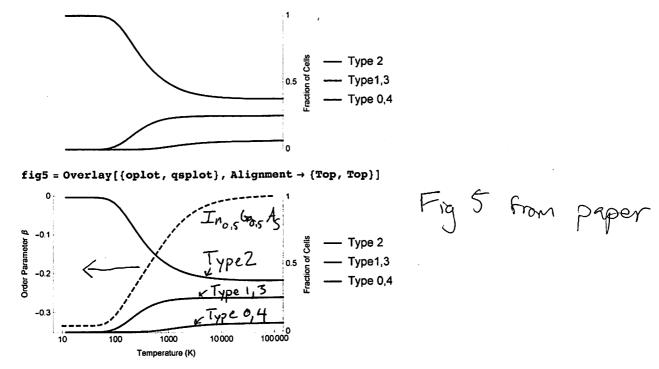
ECE5570HW4.nb | 7

The above graph shows the difference in distribution of tetrahedra types between random arrangement of Type 0-4 tetrahedra and an actual material,  $ln_{1-x}$  Ga<sub>x</sub> As at 1000K. The real material shows more preference for a given tetrahedra that matches its global composition compared to the random arrangement. This is due to the differences in energies of the tetrahedra due to strain.

```
log 57 = order Param[x_, temp] := 1 - (q1[x, temp] + 2 * q2[x, temp] + q3[x, temp]) / x / (1 - x);
     fig4 = Plot[{orderParam[x, 500], orderParam[x, 1000], orderParam[x, 2000]},
        \{x, 0, 1\}, AxesLabel \rightarrow \{\text{"Composition } x\text{", "Order Parameter }\beta\text{"}\},
        PlotLegends \rightarrow {"500 K", "1000 K", "2000 K"}, PlotRange \rightarrow {{0, 1}, {-0.4, 0}}]
     Order Parameter B
         0.0
                                                                                    Fig 4 from Paper
                   0.2
                           0.4 2000° 14
        ~0.1
                              WOK
                                                                       500 K
                                                                       1000 K
                               500 K
        -0.2
                                                                    --- 2000 K
        -0.3
        -04
```

The above plot shows the difference in order parameter given temperature and composition. A more negative order parameter represents more order in the structure. At lower temperatures, there is a preference for more long range ordering of tetrahedra because at lower temperature enthalpy is more important to lower the free energy. At higher temperatures increasing configurational entropy is more important lower free energy so ordering is not as preferred. As the composition of the InGaAs mixture approaches 50:50 the tetrahedra have more configurational coordination in order to lower the energy.





The above plot shows the effect of temperature on order parameter and type of tetrahedra present in an  $In_{0.5}$  Ga $_{0.5}$  As compound. As seen in the previous figure, increasing temperature results in order parameter approaching 0 due to the favoring of configurational entropy/randomness at high temperatures. At low temperatures the Type 2 tetrahedra (50:50 split) are highly favored because they have the lowest strain energy given the global composition. As temperature is increased, more randomness in the tetrahedra composition can occur and other types of tetrahedra can exist. At very high temperatures, the compound approaches the random approximation seen in the duplication of Figure 3. All tetrahedras begin to occur based solely on configurational statistics rather than considering the strain energy of the each tetrahedra.